

- 1) A sample of silicon is uniformly doped with  $10^{16}$  arsenic atoms per  $\text{cm}^3$  and  $5 \times 10^{15}$  boron atoms per  $\text{cm}^3$ . Assuming  $n_i$  is  $10^{10} \text{ cm}^{-3}$  at 300K determine the following for this sample at  $\sim 300\text{K}$ :
- The type ( $n$  or  $p$ )
  - The majority carrier concentration
  - The minority carrier concentration

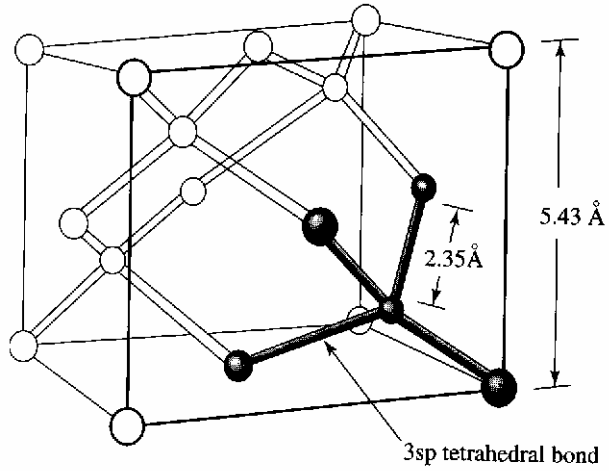
Repeat when:

- The sample instead contains  $10^{17} \text{ cm}^{-3}$  Al and  $10^{16} \text{ cm}^{-3}$  Sb.
- The sample instead contains  $10^{15} \text{ cm}^{-3}$  Ga and  $5 \times 10^{15} \text{ cm}^{-3}$  B.

- 2) How large must  $|N|/n_i$  be in order for the minority carrier concentration to be less than 10 percent of the majority density? Less than 1 percent?
- 3) Five different semiconductors and their bandgap energies are listed below. For each semiconductor calculate the longest wavelength of light that will pass through it, without being absorbed to create electron-hole pairs. Note that wavelength in microns and energy in electron volts are related as  $\lambda (\mu\text{m}) = 1.237/E_g (\text{eV})$ , and that visible light falls between  $0.4 \mu\text{m}$  and  $0.7 \mu\text{m}$ .
- |         |                     |                          |
|---------|---------------------|--------------------------|
| a. AlSb | aluminum antimonide | $E_g = 1.63 \text{ eV}$  |
| b. GaP  | gallium phosphide   | $E_g = 2.24 \text{ eV}$  |
| c. ZnS  | zinc sulfide        | $E_g = 3.6 \text{ eV}$   |
| d. InAs | indium arsenide     | $E_g = 0.33 \text{ eV}$  |
| e. Si   | silicon             | $E_g = 1.124 \text{ eV}$ |
- 4) In modern VLSI processes, the dimensions of device structures are less than  $1 \mu\text{m}^3$ . For a donor concentration  $N_d = 5 \times 10^{15} \text{ cm}^{-3}$ , find the number of electrons and the number of holes in this volume. Note: this is one of the reasons why there is a tendency for doping concentrations to increase as device dimensions are scaled into the submicron region.
- 5) Given the crystalline structure of silicon in the diamond lattice as shown in the figure on the following page and the lattice spacing of  $5.43 \text{ \AA}$  per unit cell, compute the atomic density of pure silicon (in atoms per cubic cm).

Research question:

Neils Bohr was awarded the Nobel Prize in physics in 1922 “for his services in the investigation of the structure of atoms and of the radiation emanating from them”. For what element(s) does Bohr’s model hold, and what is his prediction for the energy levels of those atoms?



► **Figure 2.1** Unit cell of crystalline silicon (After R. S. Muller and T.I. Kamins, *Device Electronics for Integrated Circuits*, 2<sup>nd</sup> ed., Wiley, 1986.)

adapted from Microelectronics: an integrated approach, Howe/Sodini, 1997.